

Supplementary Information

Indirect oxidation of aluminum under an AC electric field

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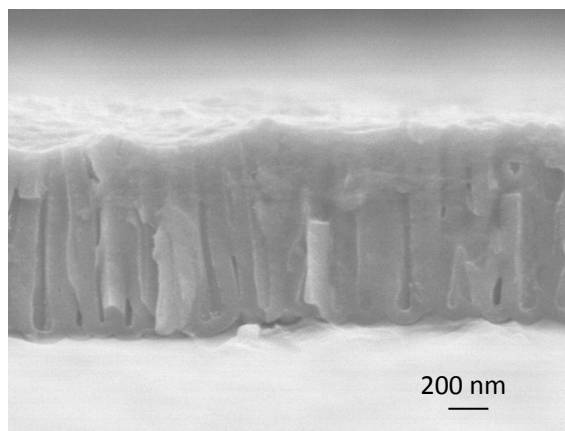


Figure S1 SEM image of the anodic oxide film formed via conventional DC anodization in 8 mmol·dm⁻³ oxalic acid at 20 °C under 60 V for 30 min.